

In the Specification:

Please amend paragraph [0052] as follows:

A1

[0052] FIG. 6 illustrates ~~a method forming a TFT of a pixel region by a sequential lateral solidification (SLS) method~~ in the active matrix organic electroluminescence display device according to a first embodiment of the present invention;

Please amend paragraph [0053] as follows:

[0053] FIG. 7 illustrates ~~a method forming a pixel region and a TFT of a driving IC for driving the pixel region by an SLS method~~ in the active matrix organic electroluminescence display device according to a second embodiment of the present invention;

Please amend paragraph [0063] as follows:

A2

FIG. 7 illustrates ~~a method forming~~ a pixel part and a TFT of a driver IC for driving the pixel part by an SLS method in the active matrix organic electroluminescence display device according to the second embodiment of the present invention.